IN THE UNITED STATES I		45
FOR THE EASTERN DISTRI	CI OF NEW TORK	1).
PLASMA PHYSICS CORPORATION,	Plaintiff,	
v .	Civil Action No	
HITACHI, LTD., HITACHI AMERICA, LTD.,)	
and HITACHI SEMICONDUCTOR (AMERICA	A) INC.,) JURY TRIAL) DEMANDED ()	2 L
	Defendants.)	.a way

COMPLAINT

This complaint is filed to effectuate Judge Wexler's July 24, 2006 ALL, M.J. ruling with respect to Hitachi, Ltd., Hitachi America, Ltd., and Hitachi Semiconductor (America) Inc., and Civil Action No. CV-99-8593. In accordance with Judge Wexler's ruling, the filing date of this complaint relates back to the December 28, 1999 filing date for Civil Action No. CV-99-8593 for all substantive issues in the original complaints, including damages pursuant to 35 U.S.C. § 286. Therefore, plaintiff, Plasma Physics Corporation ("Plasma Physics"), for its complaint against defendants, Hitachi, Ltd., Hitachi America, Ltd., and Hitachi Semiconductor (America) Inc., alleges as follows:

JURISDICTION

This is an action for patent infringement under the laws of the United States, Title 35, United States Code. Jurisdiction and venue are based on Sections 1338(a), 1391(b), 1391(c), 1391(d), and/or 1400(b) of Title 28, United States Code.



PARTIES

- Plaintiff Plasma Physics is a New York corporation with its principal place of business at 40 Overlook Road, Locust Valley, New York 11560, within this judicial district.
- 3. Upon information and belief, defendant Hitachi, Ltd. is a Japanese corporation having a place of business at 6, Kanda-Surugadai 4-chome, Chiyoda-Ku, Tokyo, 101-8010, Japan. Upon information and belief, in connection with the acts of infringement complained of herein, Hitachi, Ltd. has and is (a) transacting business within New York, (b) contracting to supply goods or services in New York, (c) committing tortious acts within New York, and/or (d) committing tortious acts without New York causing injury to persons and property within New York, and (i) regularly does or solicits business, or derives substantial revenue from goods used or consumed or services rendered, in New York or (ii) expects or should reasonably expect its tortious acts to have consequences in New York and derives substantial revenue from interstate or international commerce. In addition, upon information and belief, Hitachi, Ltd. has and is, in connection with the acts of infringement complained of herein, purposely directing into the stream of commerce semiconductor components included in Hitachi electronic products or to be included in electronic products made by others with the expectation that such electronic products will be purchased and used in New York.
- 4. Upon information and belief, defendant Hitachi America, Ltd., a wholly owned subsidiary of Hitachi, Ltd., is a New York corporation having a place of

business at 50 Prospect Avenue, Tarrytown, New York 10591 and is doing business in New York.

5. Upon information and belief, defendant Hitachi Semiconductor (America) Inc., is a wholly owned subsidiary of Hitachi Ltd., is a Delaware corporation with a place of business at 21 Old Main Street, Fishkill, New York 12524-1848, is registered to do business and is doing business in New York, and has a registered agent for service of process in New York.

THE PATENTS IN SUIT

- 6. United States Patent 4,226,897 (the "897 patent"), entitled "Method of Forming Semiconducting Materials and Barriers," duly and legally issued to Plasma Physics on October 7, 1980, based on an application filed on December 5, 1977 by John H. Coleman. Plasma Physics is the owner of title to the '897 patent and has the right to recover for past infringement thereof with respect to the following subject matter areas: apparatus for performing plasma chemical vapor coating or plasma chemical vapor etching of disc-shaped wafers made of single crystal silicon, polycrystal silicon, single crystal III-V compounds or polycrystal III-V compounds; disc-shaped wafers made with such apparatus by plasma chemical vapor coating or plasma chemical vapor etching; and processes in combination with such apparatus (the "Excluded Subject Matter").
- 7. United States Patent 5,470,784 (the "784 patent"), entitled "Method of Forming Semiconducting Materials and Barriers Using A Multiple Chamber Arrangement," duly and legally issued to Plasma Physics on November 28, 1995, based on an application filed on September 23, 1992 by John H. Coleman. Plasma Physics is the

owner of title to the '784 patent and has the right to recover for past infringement thereof in the areas of the Excluded Subject Matter.

CLAIMS FOR PATENT INFRINGEMENT

- 8. Upon information and belief, defendants Hitachi, Ltd., Hitachi America, Ltd. and Hitachi Semiconductor (America) Inc., have infringed one or more claims of the '897 and '784 patents, and are continuing to infringe one or more claims of the '784 patent, in violation of 35 U.S.C. §§ 271 (a), (b) and/or (g) by making, using, offering to sell, selling and/or importing into the United States semiconductor wafer products made by processes claimed in one or more claims of the '897 and '784 patents and/or by actively inducing infringement of one or more claims of the '897 and '784 patents.
- 9. Notice of infringement has been given to Hitachi, Ltd, and thereby also to its wholly owned subsidiaries Hitachi America, Ltd. and Hitachi Semiconductor (America) Inc.
- 10. Upon information and belief, Hitachi, Ltd.'s, Hitachi America, Ltd.'s, and Hitachi Semiconductor (America) Inc.'s infringement has been willful and deliberate.

WHEREFORE, plaintiff Plasma Physics Corporation prays for judgment and relief against defendants, including:

A. Adjudging each of the '897 and '784 patents to be not invalid and to be enforceable;

- B. Adjudging that each of the defendants has infringed and induced infringement of said patents;
- C. Permanently enjoining Hitachi, Ltd., Hitachi America, Ltd., and Hitachi Semiconductor (America) Inc., and their officers, agents, servants, employees, attorneys, all parent and subsidiary corporations, their assigns and successors in interest, and those persons in active concert or participation with any of them who receive notice of the injunction, including distributors and customers, from continuing acts of infringement of the '784 patent;
- D Adjudging that an accounting be had for damages caused by the defendants' infringement, together with pre-judgment and post-judgment interest;
- E. Adjudging that defendants are willful infringers and trebling the aforesaid damages pursuant to 35 U.S.C. § 284;
- F. Adjudging that this case is an exceptional case and awarding

 Plasma Physics Corporation its costs, expenses and reasonable attorney's fees pursuant to

 35 U.S.C. § 285; and

G. Such other and further relief as this Court may deem just and

proper.

Trial by Jury is hereby demanded.

Dated: August 4, 2000

HERBERT F. SCHWARTZ (HS2599) PATRICIA A. MARTONE (PM2989) ERIC R. HUBBARD (EH9798)

FISH & NEAVE 1251 Avenue of the Americas New York, New York 10020 (212) 596-9000

EDWARD F. MULLOWNEY (EM0673) MARK D. ROWLAND (MR8361) FISH & NEAVE 525 University Avenue Palo Alto, California 94301 (415) 617-4000

Attorneys for Plaintiff,
Plasma Physics Corporation

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☐ 791 Empl. Ret. Inc. Security Act (CITE THE U.S. CIVIL STATUTE UNDER WHICH YOU ARE FILING AND WRITE BRIEF STATEMENT OF CAUSE. DO NOT CITE JURISDICTIONAL UNLESS DIVERSITY.) VI. CAUSE OF ACTION

This is an action for patent infringement arising under the Patent Laws of the United States, Title 35, United States Code, and more particularly under Sections 271, 281, 284 and 285 of that Title.

VII. REQUESTED IN COMPLAINT:	CHECK IF THIS IS A CLASS ACTION UNDER F.R.C.P. 23	DEMAND \$	CHECK YES only if demanded in complaint: JURY DEMAND: YES □ NO
VIII. RELATED CASE(S	(See instructions): JUDGE Wexler		99-8593, DOCKET NUMBER 00-2199, 00-3146
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FOR OFFICE USE ONLY			
RECEIPT#	AMOUNT APPLYING IFP	JUDGE	MAG. JUDGE

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ARBITRATION CERTIFICATION

Herbert F. Schwart do hereby of my knowledge and belief the damage	certify pursuant to the Loc	counsel for Plasma Physics Co al Civil Rule 83.10, at (d) (3), that to t	he best
\$150,000 exclusive of interest and costs		capuoned civil action exceed the sunt	U1
Injunctive Relief other th	an monetary damages is s	ught.	
DISCLOSURE OF IN	TERESTED PARTIE	S - LOCAL CIVIL RULE 1. 9	krasw Z ca.
Identify any corporate parents,	subsidiaries or affiliates o	named corporate parties:	
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Did the cause arise in Nassau or Suffolk	County? Yes		
f you answered yes, please indicate whi	ch county. Nassau		
ounty of residence of plaintiff(s) (1)_	Nassau		
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County of residence of defendant(s)	(1) SEE ATTACHED (2)		
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This information must be provide BAR CODE: HS2599		11.1(b) of the local civil rules)	TORNEY
E-MAIL ADDRESS HSCHWARTZ	@FISHNEAVE.COM		

Defendant	County of Residence
Hitachi, Ltd.	6, Kanda-Surugadai 4-chome Chiyoda-Ku, Tokyo, 101-8010 JAPAN
Hitachi America, Ltd.	50 Prospect Avenue Tarrytown, NY 10591 (Westchester County)
Hitachi Semiconductor (America) Inc.	21 Old Main Street Fishkill, NY 12207-2543 (Dutchess County)